		449U.S. DEPARTM		ATTY. DOCKET NO. NSL-025			SERIAL NO. 10/782,545	
LIST OF PRIOR ART CITED BY APPLICANT  (Use several sheets if necessary)					APPLICANT Martin R. Roscheisen et al.			
					FILING DATE February 19, 2005		GROUP 1762	
×	T		U.S. P.	ATENT D	OCUMENTS			
EXAMINER INITIAL		DOCUMENT NUMBER	DATE		NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
FOREIGN PATENT  DOCUMENT DATE CO  NUMBER					DOCUMENTS OUNTRY CLASS SUBCLASS TRANSLATION			
		OTHER PRIOR	ART (Incl	uding Auth	or, Title, Date, P	ertinent P	ages, Etc.)	
Lisa	A	US Patent Application 10/782,163 to Brian M. Sager filed February 19, 2005 entitled "Device based on coated nanoporous structure" (NSL-024)						
HEAD	В	US Patent Application 10/782,233 to Karl Pichler filed February 19, 2005 entitled "Roll-to-roll atomic layer deposition method and system" (NSL-026)						
HEA	С	US Patent Application 10/782,017 to Dong Yu et al. filed February 19, 2005 entitled "Solution-based fabrication of photovoltaic cell" (NSL-029)						
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		Initial if reference considered. In						through citation if